Ref	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	(("6049092") or ("20020024119")). PN.	USPAT; USOCR	OR	OFF	2005/09/14 09:17
L3	0	("20020024119").PN.	USPAT; USOCR	OR	OFF	2005/09/14 09:18
L4	1	"20020024119"	US-PGPUB; USPAT	OR	ON	2005/09/14 09:18
S1	854	257/384	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 12:27
S2	176	S1 and ((ti or titanium) with (ni or nickel))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 12:27
S3	136	S1 and ((ti or titanium) adj5 (ni or nickel))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 12:28
S4	3960	((257/640,642,649,651) or (438/761,763,778,780,781,783,786, 791,793,794)).CCLS.	USPAT; USOCR	OR	OFF	2005/09/09 12:29
S5	2094	S4 and (SiN or (silicon adj nitride) or ("si.sub.3N.sub.4"))	US-PGPUB; USPAT	OR	ON	2005/09/09 12:30
S6	756179	"6" and carbon	US-PGPUB; USPAT	OR	ON	2005/09/09 12:30
S7	600	S5 and carbon	US-PGPUB; USPAT	OR	ON	2005/09/09 12:30
S8	593	S7 and (@ad<"20030805" or @rlad<"20030805")	US-PGPUB; USPAT	OR	ON	2005/09/09 12:31
S9	109	S4 and ((SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")) with carbon)	US-PGPUB; USPAT	OR	ON	2005/09/09 12:33
S11	205	S4 and ((SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")) same carbon)	US-PGPUB; USPAT	OR	ON	2005/09/09 14:20
S12	3	(("6271594") or ("5866920") or ("6333547")).PN.	USPAT; USOCR	OR	OFF	2005/09/09 12:35
S13	3780	S4 and insulating film with ((SiN or (silicon adj nitride) or ("si.sub.3N. sub.4")) same carbon)	US-PGPUB; USPAT	OR	ON	2005/09/09 14:55
S14	109	S4 and "insulating film" with ((SiN or (silicon adj nitride) or ("si.sub. 3N.sub.4")) same carbon)	US-PGPUB; USPAT	OR	ON	2005/09/09 14:20

S15	110	S4 and "insulating film" with ((SiN or (silicon adj nitride) or ("si.sub. 3N.sub.4")) same carbon)	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:09
S16	1991	S4 and insulating film with ((SiN or (silicon adj nitride) or ("si.sub.3N. sub.4")) near carbon)	US-PGPUB; USPAT	OR	ON	2005/09/09 14:55
S17	0	S4 and "insulating film" with ((SiN or (silicon adj nitride) or ("si.sub. 3N.sub.4")) near carbon)	US-PGPUB; USPAT	OR	ON	2005/09/09 14:56
S18	11	S4 and ((SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")) near carbon)	US-PGPUB; USPAT	OR	ON	2005/09/09 14:56
S19	0	S4 and "insulating film" with ((SiN or (silicon adj nitride) or ("si.sub. 3N.sub.4")) near carbon)	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:10
S20	370	S4 and "insulating film" with ((SiN or (silicon adj nitride) or ("si.sub. 3N.sub.4")) containing carbon)	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:13
S21		S4 and "insulating film containing carbon" with ((SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:13
S22	110	S4 and "carbon" with ((SiN or (silicon adj nitride) or ("si.sub:3N. sub.4"))))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	ŌR	ON	2005/09/09 15:22
S23	2172	S4 and (carbon adj doped (SiN or (silicon adj nitride) or ("si.sub.3N. sub.4")))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:23
. S24	2172	S4 and ("carbon doped" (SiN or (silicon adj nitride) or ("si.sub,3N. sub.4"))))	US-PGPUB; USPAT; USOCR; EPO; JPO;	OR	ON E.	2005/09/09 15:23
			IBM_TDB			
S25	2060077	S4 and insulating film("carbon doped" (SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:24

S26	387342	S4 and "insulating film"("carbon doped" (SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR _.	ON	2005/09/09 15:24
S27	158	S4 and "insulating film" adj5 ("carbon doped" (SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:28
S28	2	S4 and ("carbon doped" near (SiN or (silicon adj nitride) or ("si.sub. 3N.sub.4")))	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/09 15:28
S29	99	"metal silicide" with "stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/09 15:59
S30	1	"metal silicide" with "metal stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/09 15:59
S31	99	"metal silicide" with "stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 11:21
S32	0	"metal on metal" with "stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/09 16:02
S33	17	"metal stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 10:36
S34	1	"metal silicide layer" with "multiple-layered structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 10:10
S35	312	(SiN and carbon) with (insulating with (film or layer))	US-PGPUB; USPAT	OR	ON	2005/09/12 10:38
S36	5	(SiN and carbon) adj4 (insulating with (film or layer))	US-PGPUB; USPAT	OR	ON	2005/09/12 10:39
S37	518	(SiN with containing carbon) adj4 (insulating with (film or layer))	US-PGPUB; USPAT	OR	ON	2005/09/12 10:49
S38	10	"silicon carbon nitride film"	US-PGPUB; USPAT	OR	ON	2005/09/12 10:55
S39	1442639	insulating layer	US-PGPUB; USPAT	OR	ON	2005/09/12 12:27
S40	587	S39 and sicn	US-PGPUB; USPAT	OR	ON	2005/09/12 10:56
S41	3962	((257/640,642,649,651) or (438/761,763,778,780,781,783,786, 791,793,794)).CCLS.	USPAT; USOCR	OR	OFF	2005/09/12 11:05
S42	109	S41 and ((SiN or (silicon adj nitride) or ("si.sub.3N.sub.4")) with carbon)	US-PGPUB; USPAT	OR	ON	2005/09/12 11:09
S43	106	S42 and (@ad<"20030805" or @rlad<"20030805")	US-PGPUB; USPAT	OR	ON	2005/09/12 11:10
S44	1	S43 and (carbon-doped with SiN)	US-PGPUB; USPAT	OR	ON	2005/09/12 11:09

126	S41 and (SiCN or (SiN or (silicon adj	US-PGPUB;	OR	ON	2005/09/12 11:10
	nitride) or ("si.sub.3N.sub.4")) with carbon)	USPAT		~··	2000,00,12 11:10
122	S45 and (@ad<"20030805" or @rlad<"20030805")	US-PGPUB; USPAT	OR	ON	2005/09/12 12:08
2	S41 and "metal silicide" with "stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 11:22
1	S41 and "metal stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 11:22
99	"metal silicide" with "stacked structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 13:39
87	S49 and (@ad<"20030805" or @rlad<"20030805")	US-PGPUB; USPAT	OR	ON	2005/09/12 11:23
3	(SiCN with chlorine) and (@ad<"20030805" or @rlad<"20030805")	US-PGPUB; USPAT	OR	ON	2005/09/12 12:14
23	(SiCN with hydrogen) and (@ad<"20030805" or	US-PGPUB; USPAT	OR	ON	2005/09/12 12:14
	@rlad<"20030805")				
1042941	insulating film	US-PGPUB; USPAT	OR	ON	2005/09/12 12:27
52933	insulating adj film	US-PGPUB; USPAT	OR.	ON	2005/09/12 12:27
10672	S54 and carbon	US-PGPUB; USPAT	OR	ON	2005/09/12 12:27
6408	S55 and (chlorine or hydrogen)	US-PGPUB; USPAT	OR	ON	2005/09/12 12:28
284	S55 and (concentration adj (chlorine or hydrogen))	US-PGPUB; USPAT	OR	ON	2005/09/12 13:08
2637418	(SiCN containing (H or hydrogen))	US-PGPUB;	OR	ON	2005/09/12 13:09
115	(SiCN same (H or hydrogen))	US-PGPUB; USPAT	OR	ON	2005/09/12 13:26
2	(SiCN same (H or hydrogen)with concentration)	US-PGPUB; USPAT	OR	ON	2005/09/12 13:09
831080	SiCNH film	US-PGPUB; USPAT	OR	ON	2005/09/12 13:27
2345384	Insulating film contains SiCNH	US-PGPUB; USPAT	OR	ON	2005/09/12 13:27
3	"Insulating film" with SiCNH	US-PGPUB; USPAT	OR	ON	2005/09/13 12:23
0	"stacked metal silicide structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 13:39
2	"stacked metal layer structure"	US-PGPUB; USPAT	OR	ON	2005/09/12 15:31
	2 1 99 87 3 23 1042941 52933 10672 6408 284 2637418 115 2 831080 2345384 3 0	 @rlad<"20030805") S41 and "metal silicide" with "stacked structure" 1 S41 and "metal stacked structure" 99 "metal silicide" with "stacked structure" 87 S49 and (@ad<"20030805") 3 (SiCN with chlorine) and (@ad<"20030805") 23 (SiCN with hydrogen) and (@ad<"20030805") 23 (SiCN with hydrogen) and (@ad<"20030805") 1042941 insulating film 52933 insulating adj film 52933 insulating adj film 52934 and carbon S54 and carbon S55 and (concentration adj (chlorine or hydrogen)) (SiCN containing (H or hydrogen)) 2637418 (SiCN containing (H or hydrogen)) 2 (SiCN same (H or hydrogen))with concentration) 831080 SiCNH film 1 Insulating film contains SiCNH 3 "Insulating film" with SiCNH 0 "stacked metal silicide structure" 	@rlad<"20030805")	@rlad<"20030805")	Qariad < 20030805")

S66	76	"Insulating film" with ((SiN or (silicon adj nitride) or ("si.sub.3N. sub.4")) with (H or hydrogen) with (C or carbon))	US-PGPUB; USPAT	OR	ON	2005/09/13 12:28
S67	0	"Insulating film" with ((SiN or (silicon adj nitride) or ("si.sub.3N. sub.4")) with (H or hydrogen) with (C or carbon) with (Cl or chlorine))	US-PGPUB; USPAT	OR	ON	2005/09/13 12:26
S68	64	("Insulating film" with ((SiN or (silicon adj nitride) or ("si.sub.3N. sub.4")) with (H or hydrogen) with (C or carbon))) and (@ad<"20030805" or @rlad<"20030805")	US-PGPUB; USPAT	OR	ON	2005/09/13 13:12
S69	4	("Insulating film" with ((SiCN with (H or hydrogen))) and (@ad<"20030805" or @rlad<"20030805"))	US-PGPUB; USPAT	OR	ON	2005/09/13 13:14
S70	33	((SiCN with (H or hydrogen)) and (@ad<"20030805" or @rlad<"20030805"))	US-PGPUB; USPAT	OR	ON	2005/09/13 14:31
S71	1	"20050009320"	US-PGPUB; USPAT	OR	ON	2005/09/13 13:32
S72	16	((SiCNH) and (@ad<"20030805" or @rlad<"20030805"))	US-PGPUB; USPAT	OR	ON	2005/09/13 14:57
S73	120	((SiN) with carbon with hydrogen and (@ad<"20030805" or @rlad<"20030805"))	US-PGPUB; USPAT	OR	ON	2005/09/13 14:57